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FOR

APPARATUS INCORPORATING SMALL-FEATURE-SIZE AND LARGE-FEATURE-SIZE COMPONENTS AND METHOD FOR MAKING SAME

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APPARATUS INCORPORATING SMALL-FEATURE-SIZE AND LARGE-
FEATURE-SIZE COMPONENTS AND METHOD FOR MAKING SAME

BACKGROUND OF THE INVENTION

5 Field of the Invention

[001] The field of the invention generally relates to apparatuses having both large-feature-size components and small-feature-size components, and methods of making such apparatuses. The invention more particularly relates to combination of VLSI integrated circuits and macro-scale components to form a
10 single device.

Description of the Related Art

[002] VLSI provides many effective methods for creation of microscopic-scale and smaller components. Such miniaturization provides many advantages
15 in terms of speed of operation, size of footprint, amount of necessary resources, and speed of manufacture for electronic devices.

[003] Unfortunately, some components of electronic devices are not well-suited to formation through well-known VLSI processes. These components often are necessarily very large (macroscopic-scale) relative to devices or
20 components of devices formed through VLSI. One such component is an antenna, which may need to have a characteristic length to allow for adequate transmission on a preferred frequency, and for which the characteristic length in

question may be appropriately measured in centimeters or meters for example. Formation of a conductor for use as an antenna using VLSI tends to waste time and material resources, as a 30 cm conductor (for example) can easily be formed through less expensive processes.

5 [004] Thus, the problem then becomes a matter of combining a large-scale component such as an antenna with a small-scale component such as an integrated circuit. For a conventional radio, this may involve use of packaging for the integrated circuit, conductors on a printed circuit board, a connector attached to the printed circuit board, and an antenna attached to the connector. This
10 approach is simple enough for a device having rigid packaging and flexible size constraints. However, other applications may have more demanding requirements for size and materials cost.

 [005] In particular, it may be useful to have a small radio-transmitter with flexible materials allowing for bending and other abusive actions without
15 degradation in functionality. Similarly, such a small radio-transmitter may need to be producible rapidly in quantities of millions or billions, thus requiring ease of assembly and relatively inexpensive materials on a per-unit basis. Using a printed-circuit board approach for such a radio-transmitter will likely not succeed. Moreover, avoiding such time (and/or space) consuming processing operations
20 as thermal cure may be advantageous.

 [006] It is possible to separately produce elements, such as integrated circuits and then place them where desired on a different and perhaps larger

substrate. Prior techniques can be generally divided into two types:

deterministic methods or random methods. Deterministic methods, such as pick and place, use a human or robot arm to pick each element and place it into its corresponding location in a different substrate. Pick and place methods place

5 devices generally one at a time, and are generally not applicable to very small or numerous elements such as those needed for large arrays, such as an active matrix liquid crystal display. Random placement techniques are more effective and result in high yields if the elements to be placed have the right shape. U.S. Patent No. 5,545,291 and U.S. Patent No. 5,904,545 describe methods that use
10 random placement. In this method, microstructures are assembled onto a different substrate through fluid transport. This is sometimes referred to as fluidic self assembly (FSA). Using this technique, various integrated circuits, each containing a functional component, may be fabricated on one substrate and then separated from that substrate and assembled onto a separate substrate
15 through the fluidic self assembly process. The process involves combining the integrated circuits with a fluid, and dispensing the fluid and integrated circuits over the surface of a receiving substrate that has receptor regions (e.g., openings). The integrated circuits flow in the fluid over the surface and randomly align onto receptor regions, thereby becoming embedded in the substrate.

20 [007] Once the integrated circuits have been deposited into the receptor regions, the remainder of the device can be assembled. Typically, this involves coating the substrate with a planarization layer to provide electrical insulation and

physical retention for the integrated circuits. The planarization layer creates a level surface on top of the substrate by filling in the portions of the receptor regions that are not filled by integrated circuits. After the planarization layer has been deposited, other elements, including pixel electrodes and traces for

5 example, may be installed.

[008] Using FSA, the functional components of the device can be manufactured and tested separately from the rest of the device.

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SUMMARY OF THE INVENTION

[009] The present invention relates generally to the field of fabricating elements on a substrate. In one embodiment, the invention is an apparatus. The apparatus includes a substrate having embedded therein an integrated circuit, the integrated circuit having a conductive pad. The apparatus further includes a conductive medium attached to the conductive pad of the integrated circuit. The apparatus also includes a large-scale component attached to the conductive medium, the large-scale component electrically coupled to the integrated circuit.

[010] In an alternate embodiment, the invention is a method. The method includes attaching a conductive medium to a substrate having embedded therein an integrated circuit such that the conductive medium is connected electrically to the integrated circuit. The method also includes attaching a large-scale component to the conductive medium such that the large-scale component is electrically connected to the conductive medium.

[011] In another alternate embodiment, the invention is an apparatus. The apparatus includes an integrated circuit embedded within a substrate. The apparatus also includes a thin-film dielectric layer formed over a portion of the integrated circuit and a portion of the substrate. The apparatus further includes a conductive medium formed over a portion of the thin-film dielectric layer, the conductive medium having direct electrical connection with the integrated circuit.

[012] In yet another alternate embodiment, the invention is a method.

The method includes forming a thin-film insulator on a portion of an integrated circuit and a portion of a substrate, the integrated circuit being embedded within the substrate. The method also includes attaching a conductive medium to the

5 thin-film insulator and to the integrated circuit, the conductive medium electrically connected to the integrated circuit.

[013] In still another alternate embodiment, the invention is an apparatus.

The apparatus includes a strap comprising a substrate with an embedded integrated circuit, the integrated circuit having a conductive pad, and a

10 conductive medium attached to the conductive pad of the integrated circuit.

BRIEF DESCRIPTION OF THE DRAWINGS

[014] The present invention is illustrated by way of example and not limitation in the accompanying figures.

[015] Figure 1 illustrates a side view of an embodiment of a strap.

5 [016] Figure 2 illustrates a side view of an embodiment of the strap of Figure 1 as attached to a large-scale component.

[017] Figure 3A illustrates a view of an embodiment of the apparatus of Figure 1 along the line A-A in the direction indicated.

10 [018] Figure 3B illustrates a view of an embodiment of the apparatus of Figure 2 along the line B-B in the direction indicated.

[019] Figure 4 illustrates an embodiment of an antenna.

[020] Figure 5 illustrates an embodiment of a tape spool having adhered thereon straps including Nanoblock ICs.

15 [021] Figure 6 illustrates an embodiment of a method of forming an apparatus including both small-feature-size and large-feature-size components.

[022] Figure 7 illustrates an alternate embodiment of a method of forming an apparatus including both small-feature-size and large-feature-size components.

20 [023] Figure 8 illustrates an alternate embodiment of a strap from a side view.

[024] Figure 9 illustrates yet another alternate embodiment of a strap from a side view.

[025] Figure 10 illustrates a side view of still another alternate embodiment of a strap.

[026] Figure 11 illustrates another alternate embodiment of a method of forming an apparatus including both small-feature-size and large-feature-size components.

[027] Figure 12A illustrates a top view of another embodiment of a substrate.

[028] Figure 12B illustrates a side view of another embodiment of a substrate.

[029] Figure 13 illustrates a side view of yet another embodiment of a substrate.

[030] Figure 14 illustrates a side view of still another embodiment of a substrate.

DETAILED DESCRIPTION

[031] An apparatus incorporating small-feature-size and large-feature-size components and method for making same is described. In the following description, for purposes of explanation, numerous specific details are set forth
5 in order to provide a thorough understanding of the invention. It will be apparent to one skilled in the art, however, that the invention can be practiced without these specific details. In other instances, structures and devices are shown in block diagram form to avoid obscuring the invention.

[032] Reference in the specification to “one embodiment” or “an
10 embodiment” means that a particular feature, structure, or characteristic described in connection with the embodiment is included in at least one embodiment of the invention. The appearances of the phrase “in one embodiment” in various places in the specification are not necessarily all referring to the same embodiment, nor are separate or alternative embodiments
15 mutually exclusive of other embodiments.

[033] The present invention relates generally to the field of fabricating elements on a substrate. In one embodiment, the invention is an apparatus. The apparatus includes a strap, including a substrate with an embedded integrated circuit, , and a conductive medium attached to the conductive pad of
20 the IC. The apparatus also includes a large-scale component attached to the conductive medium, the large-scale component electrically coupled to the integrated circuit.

[034] In an alternate embodiment, the invention is a method. The method includes creating a strap by attaching a conductive medium to a substrate with an embedded integrated circuit such that the conductive medium is connected electrically to the integrated circuit. The method also includes

5 attaching a large-scale component to the conductive medium such that the large-scale component is electrically connected to the integrated circuit. The conductive medium may be applied by screen, stencil, or ink jet printing, laminating, hot pressing, laser assisted chemical vapor deposition, physical vapor deposition, shadow masking, evaporating, extrusion coating, curtain

10 coating, electroplating, or other additive techniques. The conductive medium may be a fluid, silver ink, electrically conductive tape (thermoplastic or thermosetting polymer with conductive filler), electrically conductive paste (solder paste or conductive filler in a polymer matrix), solder, metal film, metal particles suspended in a carrier, conductive polymer, carbon-based conductor, or other

15 thick-film material for example. One exemplary conductive medium product is Acheson Colloids Electrodag 4795

[035] In another alternate embodiment, the invention is an apparatus. The apparatus includes an integrated circuit embedded within a substrate. The apparatus also includes a thin-film dielectric layer formed over a portion of the

20 integrated circuit and a portion of the substrate. The apparatus further includes a conductive medium formed over a portion of the thin-film dielectric layer, the

conductive medium having direct electrical connection with the integrated circuit.

The apparatus is called a strap.

[036] In yet another alternate embodiment, the invention is a method.

The method includes forming a thin-film insulator on a portion of an integrated
5 circuit and a portion of a substrate, the integrated circuit embedded within the
substrate. The method also includes attaching a conductive medium to the thin-
film insulator and to the integrated circuit, the conductive medium electrically
connected to the integrated circuit.

[037] In still another alternate embodiment, the invention is an apparatus.

10 The apparatus includes a substrate having embedded therein an integrated
circuit, the integrated circuit having a conductive pad. The apparatus also
includes a conductive medium attached to the conductive pad of the integrated
circuit. This apparatus is referred to as a strap.

[038] In yet another alternate embodiment, the invention is an apparatus.

15 The apparatus includes a strap having embedded therein a Nanoblock™ IC
(Nanoblock is a trademark of ALIEN Technology Corporation) and a conductor
electrically coupled to the Nanoblock IC. The Nanoblock IC may have been
produced using conventional VLSI procedures and embedded using fluidic self-
assembly (FSA) for example. The substrate has attached thereon a conductive
20 medium, allowing for electrical coupling between the Nanoblock IC and the
conductor. Attached to the conductive medium is a substrate including an

antenna, allowing for electrical coupling between the antenna and the Nanoblock IC.

[039] In still another alternate embodiment, the invention is a method.

The method includes attaching a conductive medium to a substrate having

5 embedded therein a Nanoblock IC such that the conductive medium is coupled electrically to the Nanoblock IC, thereby forming a strap. The method further

includes attaching a large-scale component to the conductive medium such that the large-scale component is electrically connected or coupled to the conductive

medium. The method may further include fabricating the Nanoblock IC and

10 performing FSA to embed the Nanoblock IC in the substrate. The method may

also involve a large-scale component which may be an antenna, a power source such as a battery or a button cell, or a thick-film cell printed on the strap or other

substrate; a display electrode or a display; a logic device, or a sensor; among other examples.

15 [040] In a further alternate embodiment, the invention is an apparatus.

The apparatus includes a substrate having embedded therein a Nanoblock IC.

The substrate has attached thereto a conductive medium , allowing for electrical connection between the Nanoblock IC and the conductive medium. Attached to

the conductive medium is a substrate such as an antenna, allowing for electrical

20 coupling between the antenna and the Nanoblock IC.

[041] For purposes of the discussion in this document, both the previous statements and following statements, a distinction must be made between thin

film and thick film processes. Thin films are applied through use of vacuum or low-pressure processes. Thick films are applied using non-vacuum processes, typically at or near atmospheric pressure. One having skill in the art will appreciate that exact magnitudes of ambient pressure for low-pressure of vacuum as opposed to atmospheric pressure may be difficult to state. However, one having skill in the art will also appreciate that the differences between low-pressure and atmospheric pressure are relatively large compared to atmospheric pressure.

[042] Figure 1 illustrates a side view of an embodiment of a strap, including a substrate with an embedded Nanoblock IC, planarizing layer, and conductive medium that contacts the pad on the NanoBlock™ IC. The substrate 110 has an opening in it to contain the Nanoblock IC, and may be a flexible plastic substrate for example. Nanoblock IC 120 is a Nanoblock IC formed via conventional VLSI. The Nanoblock IC 120 may be embedded in the opening of the substrate 110 through FSA for example. Nanoblock IC 120 may have a variety of functions or structures consistent with an integrated circuit. In one embodiment, Nanoblock IC 120 includes circuitry suitable for receiving radio signals from an external antenna and sending radio signals via the external antenna. Moreover, in one embodiment, Nanoblock IC 120 may receive power from an external source via an external antenna, and use such power to send a radio signal via the external antenna.

[043] Formed above Nanoblock IC 120 is planarization layer 130, which may be formed through a conventional thin-film deposition, pattern and etch or other similar method, and which may be formed of an insulating material such as silicon dioxide for example. Formed above planarization layer 130 are two
5 conductors 140, which may be formed from a screen-printed electrically conductive paste for example, and which occupy two contact holes in the planarization layer 130. Preferably, the two conductors 140 attach to conductive pads of Nanoblock IC 120, and the two conductors 140 preferably do not directly connect to each other. Formed above conductors 140 is insulating layer 150
10 which may be formed through a thin-film or thick-film process for example, and may fill in space between the two conductors 140. As will be appreciated, a conductor may in some instances connect to multiple pads of an integrated circuit by design. One example of such a situation is connecting all ground pads of an IC to a single conductor to achieve a common ground potential.

15 [044] As will be appreciated, Nanoblock IC 120 may be formed with sufficiently large pads as to allow for direct connection between the two conductors and the Nanoblock IC, thereby avoiding the requirement of an intervening conductor. As will also be appreciated, such a structure will, in some embodiments, require direct (vertical) connection between any large-scale
20 component and the Nanoblock IC through the conductive medium, as some conductive media have isotropic conductivity. Furthermore, note that conductive media may include metal particles suspended in a carrier, conductive polymers,

paste, silver ink, carbon-based conductors, solder, and other conductors. Also, note that the large-scale component discussed in this application may be an antenna, an electronic display or display electrode, a sensor, a power source such as a battery or solar cell, or another logic or memory device (such as but
5 not limited to microprocessors, memory, and other logic devices), for example.

[045] Figure 2 illustrates a side view of an embodiment of the strap of Figure 1 as attached to a large-scale component. Conductors 270 each have a direct connection to one of the conductors 140, and potentially having a connection to one or more of insulation layer 150, planarization layer 130, and
10 substrate 110. Attached to each of conductors 270 are one of conductors 280, which may be conductive pads of an antenna or conductive ends of an antenna for example. Thus, as illustrated, each of conductors 280 may be said to be coupled (electrically) to Nanoblock IC 120. Substrate 290 is the material in which conductors 280 are embedded or to which conductors 280 are attached,
15 and is preferably insulating in nature.

[046] Space 260 is a space between the two conductors 270, which may be occupied by substrate 290 and/or insulator 150, or may be left as a void in the structure. It is important to note that in most applications, each of the two conductors 270 would not be connected directly to the other conductor 270, and
20 a similar statement may be made with respect to the two conductors 280.

[047] In one embodiment, the conductive medium 270 is an electrically conductive tape (such as those available from the Sony Corporation, including

Sony DP1122, for example). Moreover, the conductive tape may be isotropically or anisotropically conductive. Such a conductive tape may be applied (adhered) by rolling the tape along a row of straps, applying sufficient pressure and possibly heat to adhere the tape to the straps, and then cutting the tape to
5 separate the individual straps. This may be done in various manners.

[048] Alternatively, the conductive medium 270 or 140 may be a conductive paste (such as those available from Ablestick, including Ablebond 8175A for example) which is put on the strap(s) through a screen printing process for example. Such a paste may be screened on to the straps at
10 moderate resolutions relative to overall manufacturing tolerances, thereby allowing for useful connection to conductors 140. Furthermore, a conductive medium 270 may also be a metal particles suspended in a carrier, a conductive polymer, a carbon-based conductor, a solder, or other conductive medium as will be appreciated by those skilled in the art.

[049] Figure 3A illustrates a view of an embodiment of the strap of Figure 1 along the line A-A in the direction indicated. The various overlaps between substrate 110, Nanoblock IC 120, planarization layer 130, conductors 140 and insulation layer 150 are all illustrated. Moreover, contact holes 315 in the planarization layer 130 are illustrated, thus making apparent the connection
15 between conductors 140 and Nanoblock IC 120.

[050] Figure 3B illustrates a view of an embodiment of the apparatus of Figure 2 along the line B-B in the direction indicated. Illustrated are overlaps

between conductive layers 140, insulation layer 150, and conductors 280. For clarity, substrate 110 is also shown and substrate 290 is not shown.

[051] Figure 4 illustrates an embodiment of an antenna. Each arm 455 is connected to antenna conductor pads 280. Note that in an alternate
5 embodiment, arms 455 may simply form conductor pads 280, making them a single unitary structure of both arm and pad.

[052] Figure 5 illustrates an embodiment of a tape spool having adhered thereon straps including Nanoblock ICs. Each strap 505 (of which one exemplary strap 505 is labeled) is adhered to a pair of electrically conductive
10 tape strips 515. The tape strips 515 form part of a larger spool which also includes through-holes 525 for purposes of spooling. In one embodiment, the tape strips 515 may be anisotropically conductive film (ACF), with the conductors of the straps 505 adhered to the ACF. In an alternate embodiment, the conductive medium may be on a surface of the straps 505 opposite the surface
15 adhered to by tape strips 515. Moreover, the tape spools of either embodiment may be formed with gaps between columns of straps allowing for slitting the tape through the gap to produce a single column of straps.

[053] Figure 6 illustrates an embodiment of a method of forming an apparatus including both small-feature-size and large-feature-size components.

20 At block 610, the integrated circuits are fabricated, such as through a conventional VLSI method. At block 620, the integrated circuits are embedded into substrate(s). At block 630, processing for purposes of forming planarization

and insulation layers occurs, and a thick-film insulator is formed (one skilled in the art will appreciate that a thin-film insulation layer may also be formed). At block 640, conductive medium is applied to the substrate, such as by screen printing on paste or through other additive processes. At block 650, a large-scale component is attached to the conductive medium. Note that in one embodiment, the tape spool of Figure 5 may be used to attach a large volume of straps to large-scale components by attaching each strap individually and then cutting the tape after attachment. In an alternate embodiment, the conductive medium 640 is applied directly to the substrate embedded with ICs 620, omitting the insulating layer.

[054] Figure 7 illustrates an alternate embodiment of a method of forming an apparatus including both small-feature-size and large-feature-size components, with particular reference to fabrication of RF-ID tags using Nanoblock ICs. At block 710, the Nanoblock ICs are fabricated, such as through conventional VLSI methods. At block 720, the Nanoblock ICs are embedded in substrates through FSA. At block 730, any necessary post-FSA processing for purposes of forming planarization layers, and/or insulation layers occurs. In particular, at least one thin-film dielectric is formed. As will be appreciated by one skilled in the art, the thin-film dielectric may not be necessary in alternative embodiments. At block 740, a first conductive medium is applied to the substrates, such as in the form of a paste screened on to the substrates for example, thus creating straps. At block 750, electrically conductive tape is

adhered to the conductive medium on the straps. At block 760, antennas are attached to the straps, such that the antennas are electrically coupled to the Nanoblock ICs of the corresponding straps.

[055] Figure 8 illustrates an alternate embodiment of a strap from a side view. As will be appreciated, the embodiment of Figure 8 is similar to the embodiment of Figure 1. However, Figure 8 illustrates a substrate 810, having embedded therein (in an opening) an integrated circuit 820, with pads 825. Each pad has deposited thereon through use of an additive process a conductive medium 840, such as a silver ink for example. Usually, but not always, the conductive medium 840 is deposited such that it contacts one and only one pad 825 directly, thus allowing for separate conductors for each electrical contact of a circuit.

[056] Moreover, it will be appreciated that the size of the pads 825 may be greater than the size of similar pads on an integrated circuit such as Nanoblock IC 120 of Figure 1, in that the pads 825 must interface directly with material (the conductive medium 840) having a much larger feature size than is common for VLSI devices. Note that in one embodiment, the conductive medium 840 may be expected to have an as-deposited thickness of approximately 10-15 μms and a final thickness on the order of 1 μm or less, and that pads 825 may have minimum dimensions on the order of 20 x 20 μms or more.

[057] Figure 9 illustrates yet another alternate embodiment of a strap from a side view. Figure 9 illustrates a similar embodiment to that of Figure 8, which further incorporates an insulator. Substrate 910 includes integrated circuit 920 embedded therein. Pads 925 are a part of integrated circuit 920, and may
5 be expected to have similar dimensions to pads 825. Insulator (dielectric) 930 is deposited on integrated circuit 920 through use of a thick film process. Insulator 930 may be expected to have a thickness on the order of 10 (microns). Also deposited with an additive process is a conductive medium 940, which covers both an insulator 930 and some portion of a pad 925, that thereby allows for
10 electrical contact between the integrated circuit 920 and a large scale component. Conductive medium 940 may be expected to have similar characteristics to conductive medium 840.

[058] Figure 10 illustrates a side view of still another alternate embodiment of a strap. In this embodiment, the insulator (1030) is a thin-film
15 insulator patterned with vias through which the conductive medium (1040) may achieve contact with the pads (1025) of the integrated circuit (1020). As will be appreciated, the vias require greater precision in patterning than do any of the insulators of conductor components of Figures 8 and 9. Moreover, as will be appreciated, the substrate 1010 may have insulator 1030 covering nearly its
20 whole surface, rather than the limited areas of Figure 9. Additionally, it will be appreciated that the pads 1025 may be smaller on integrated circuit 1020 than similar pads of integrated circuits 920 and 820.

[059] Figure 11 illustrates another alternate embodiment of a method of forming an apparatus including both small-feature-size and large-feature-size components. At block 1110, an integrated circuit is embedded within a supporting substrate. At block 1120, a thin-film insulator is applied to the substrate. At block 1130, the insulator is patterned such as through a photolithographic thin-film process, whereby portions of the insulator are removed to expose portions of the substrate or integrated circuit, such as bond or conductive pads. Further cleaning, such as washing away photoresist for example, may be involved as part of application, patterning, or even in a post-etch phase. Alternatively, as will be appreciated, a photosensitive insulator or dielectric may be used, thereby eliminating the need for photoresist for example.

[060] At block 1140, a conductive medium is applied to the substrate, coating all or part of the insulator. At block 1150, the conductive medium is processed (such as by heat curing, for example) as necessary to form a proper conductor. Note that curing of silver ink is known in the art to be possible at 90-100°C for some formulations with a reasonable cure time for various manufacturing processes. It will be appreciated that cure times do vary, and that those skilled in the art may adapt cure processes to the needs of a surrounding manufacturing process and the devices to be produced. At block 1160, the large-scale component is attached to the conductive medium, thereby achieving electrical coupling with the integrated circuit. Also note that the final processing

of the conductive medium of block 1160 may be performed after the large scale component is attached at block 1170.

[061] For the most part, the previous description has concentrated on use of the invention in conjunction with attaching a strap having embedded
5 therein an integrated circuit to a separate large-scale component.. It will be appreciated that other embodiments exist in which the separate large-scale component is not involved. In particular, a large-feature-size component may be incorporated as part of the strap, such as an embedded conductor acting as an antenna, or may be formed on the strap as illustrated in Figures 12a and 12b.

10 Printing or otherwise using additive processing technology to form an antenna 1240 of the conductive medium on the strap is one option.

[062] Alternately, other large-feature-size components, such as power sources, sensors, or logic devices for example may either be formed on the strap or attached to the strap. Interconnecting a Nanoblock IC with such large-feature-
15 size components on the strap may be accomplished through use of conductive medium 1440, allowing for electrical coupling between the large-feature-size components 1460 and the small-feature-size (Nanoblock IC for example) components 1420, as in Figure 14. Moreover, a conductive medium 1340 may be used to interconnect two or more small-feature-size components embedded
20 in a single substrate, such as two Nanoblock ICs for example, as illustrated in Figure 13.

[063] Figure 12A illustrates a top view of another embodiment of a substrate. Substrate 1210 may be a substrate such as those discussed previously, including a flexible or rigid material. Integrated circuit (IC) 1220 is embedded in an opening in substrate 1210. Insulator 1230 is a layer of insulating material (or a dielectric layer) on top of both substrate 1210 and IC 1220 and may have planarizing properties. Contact holes 1215 are holes in the insulator 1230 above contact pads of IC 1220, allowing for physical contact and electrical connection between IC 1220 and conductive media 1240. Layer 1250 is another insulator or dielectric above portions of conductive media 1240, insulator 1220 and substrate 1210, and above all of IC 1220. Note that the actual configuration of the various layers may vary considerably. For example, conductive media 1240 is formed into two arms of an antenna, such as may be useful for radio frequency applications. However, batteries, sensors, power supplies, button cells, and displays and display electrodes may also be formed through use of conductive media and other materials.

[064] Figure 12B illustrates a side view of another embodiment of a substrate. As is illustrated, conductive media 1240 occupies the contact holes 1215 of Figure 12A to contact directly with IC 1220. Furthermore, as will be appreciated, the segments illustrated with respect to conductive media 1240 correspond to the various segments of the antenna as it traces its path along the surface of the insulator 1230. Along these lines, it will be appreciated that the presence of the insulator 1230 may not be necessary in some instances.

[065] Figure 13 illustrates a side view of yet another embodiment of a substrate. Substrate 1310 includes first integrated circuit (IC) 1320 and second integrated circuit (IC) 1325. Insulator 1330 is formed above IC 1320, IC 1325 and substrate 1310. Conductive media 1340 is formed above insulator 1330, and contacts both IC 1320 and IC 1325. One portion of conductive media 1340 forms an electrical connection between IC 1320 and IC 1325, thereby electrically coupling IC 1320 to IC 1325. Above both IC 1320 and IC 1325 are formed insulator layers 1350.

[066] Figure 14 illustrates a side view of still another embodiment of a substrate. Substrate 1410 has embedded in an opening therein an IC 1420. Formed above substrate 1410 and IC 1420 is insulator 1430. Formed above insulator 1430 and connected to IC 1420 is conductive media 1440, a portion of which is connected to sensor 1460, thereby electrically coupling IC 1420 to sensor 1460. Formed above a portion of conductive media 1440 and insulator 1430 is insulator 1450, which may or may not be of the same material as insulator 1430.

[067] In the foregoing detailed description, the method and apparatus of the present invention has been described with reference to specific exemplary embodiments thereof. It will, however, be evident that various modifications and changes may be made thereto without departing from the broader spirit and scope of the present invention. In particular, the separate blocks of the various block diagrams represent functional blocks of methods or apparatuses and are

not necessarily indicative of physical or logical separations or of an order of operation inherent in the spirit and scope of the present invention. For example, the various blocks of Figure 1 may be integrated into components, or may be subdivided into components, and may alternately be formed in different physical shapes from those illustrated. Similarly, the blocks of Figure 6 (for example) represent portions of a method that, in some embodiments, may be reordered or may be organized in parallel rather than in a linear or step-wise fashion. The present specification and figures are accordingly to be regarded as illustrative rather than restrictive.